

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant	:	Todd <i>et al.</i>
Appl. No.	:	10/623,482
Filed	:	July 18, 2003
For	:	METHOD TO FORM ULTRA HIGH QUALITY SILICON- CONTAINING COMPOUND LAYERS
Examiner	:	Ron Everett Pompey
Group Art Unit	:	2812

**AMENDMENT AND RESPONSE TO FINAL OFFICE ACTION****Mail Stop AF**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

In response to the final Office Action mailed on November 27, 2006, please amend the above-identified application as follows.

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks/Arguments** begin on page 4 of this paper.